GaInP/AlInP(001) Interfaces from Density Functional Theory

Lukas Meier* and Wolf Gero Schmidt*

1. Introduction

III–V compound semiconductors are important for various electronic and optoelectronic applications, e.g., high-electron-mobility transistors, light-emitting diodes, photodetectors, electro-optic modulators, and frequency-mixing components. Solar cells made of III–V semiconductors reach the highest efficiencies of any photovoltaic technology so far.[1] The prerequisite for such high efficiencies is the possibility to stack solar cells made of different III–V semiconductors. This enables an efficient use of the solar spectrum. Apart from the binary compounds also ternary and quaternary alloys are combined. The full exploitation of this flexibility profits from detailed knowledge of the electronic properties of III–V compounds and their alloys,[2] surfaces,[3] and interfaces.[4–7]

This motivates the present work, which addresses the electronic properties of the GaInP/AlInP interface employed, e.g., in high-efficiency tandem structures for the direct solar-to-hydrogen conversion.[8] The branch-point energy method[9–15] has recently been used to address the natural band alignment at this interface.[7] Assuming random ordering in the Ga0.5In0.5P and Al0.5In0.5P alloys, valence and conduction band offsets of 0.18 and −0.49 eV, respectively, was calculated.[7] These values, however, do not account for the influence of strain, surface orientation and interface bonding. These effects are investigated in the present study, focusing on CuPt-type ordered crystals, i.e., bulk material with alternating group III layers perpendicular to the [111] or [1T1] direction, as formed spontaneously in metal–organic vapor phase epitaxy epilayers.[16]

2. Methodology

Our study is based on density functional theory (DFT) as implemented in the Vienna ab initio simulation package (VASP).[17] The generalized gradient approximation (GGA) as well as hybrid functionals are used to model the electron exchange and correlation interaction. In particular, the revised Perdew–Becke–Ernzerhoff (PBEsol)[18] GGA functional and the Heyd–Scuseria–Ernzerhof (HSE) hybrid functional[19] are used for structural relaxations and electronic structure calculations, respectively. In the latter, the fraction of exact exchange is increased to 29% for a better match with the measured bandgaps.[7] The resulting changes in the bulk bandgaps with respect to the default mixing of 25% are small, however, compared with the conduction band offsets calculated in this work. Therefore, the choice of the mixing parameter will not affect the conclusions of the present study. The electron–ion interaction is described by the projector-augmented wave (PAW) scheme.[20,21] The electronic wave functions are expanded into plane waves up to a kinetic energy cutoff of 650 eV. For a better comparison of the interface energies, the CuPt-type ordered bulk crystals, as well as the interface systems are modeled in 192 atom cells. They contain six layers of GaInP and AlInP, stacked along the [001] direction. Each layer consists of 8 group-III atoms and 8 phosphorous atoms. The Brillouin zone integration is performed using the Monkhorst–Pack scheme with a k-point density of 2 × 2 × 1.

3. Results and Discussion

3.1. Ternary Crystal Properties

For GaP and AlP indirect bandgaps of about 2.3[22,23] and 2.5 eV[24] were measured. In contrast, InP is a direct-gap semiconductor with a bandgap of 1.4 eV.[25] The direct-indirect bandgap crossover of Ga0.5In0.5P and Al0.5In0.5P occurs for In-rich stoichiometries, respectively.[5,26–28] The measured bandgaps of randomly ordering Ga0.5In0.5P and Al0.5In0.5P alloys amount to about 1.9[29,30] and 2.3 eV.[31] In
Figure 1, we show the band structures of CuPt-type ordered GaInP and AlInP crystals, calculated at the respective equilibrium lattice constants of 5.71 and 5.70 Å obtained from structural relaxation. These lattice constants are nearly identical to the ones predicted by Vegard’s law applied to the calculated lattice constants of the respective binary compounds[7] and about 0.7% larger than the experimental values.[32] Within GGA (HSE) we calculate direct and indirect band gaps of 0.57 (1.44) and 1.26 (2.06) eV for CuPt-type ordered GaInP and AlInP, respectively. Obviously, even the HSE values somewhat underestimate the experimental data.[29–31] This is largely due to ordering effects. In fact, the bandgap energy is expected to be highest in fully disordered alloys, with increased ordering leading to a bandgap decrease due primarily to a downward motion of the conduction band, as described by Wei and Zunger.[33] This effect is experimentally confirmed for GaInP[34] and AlInP.[35] The present calculations in comparison to earlier hybrid DFT calculations based on the same numerical parameters[7] indicate that ordering effects reduce the GaInP and AlInP bandgaps by 0.18 and 0.24 eV, respectively.

3.2. Natural Band Alignment

The HSE band structures calculated here can be used to determine the natural band alignment at GaInP/AlInP interfaces for CuPt-type ordered crystals within the branch-point method. We calculate valence and conduction band offsets of 0.14 and −0.54 eV, respectively. Compared with the HSE values calculated for random alloys,[7] the CuPt ordering of the bulk material is found to reduce the valence band offset by 0.04 eV and to increase the conduction band offset by 0.05 eV. This confirms earlier theoretical work[33] showing that ordering affects the conduction states more strongly than the valence states.

3.3. Interface Formation Energies

To go beyond the branch-point methodology, we next investigate four nonsymmetry-related possibilities to realize atomically smooth interfaces between CuPt-type ordered GaInP and AlInP, see Figure 2. These are modeled here within periodic supercells, with lateral lattice constants corresponding to either GaInP or AlInP. This models the situation that either a thin AlInP film is grown on a GaInP substrate, or vice versa. Thus, both limiting interface realizations are included in the calculations. The supercell dimension along the interface normal, i.e., parallel to the [001] direction, is optimized to allow for vertical strain compensation. The interface binding energies per atom are obtained from

$$E_B = \frac{1}{16}(E_{slab} - 0.5(E_{AlInP} + E_{GaInP}))$$  (1)
where $E_{\text{slab}}$ is the total energy of the slab containing the interface and $E_{\text{AlInP}}$ and $E_{\text{GaInP}}$ are the respective bulk energies. The factor 1/16 accounts for eight atoms forming the interface and the fact that the interface occurs twice in the supercell. The interface energies vary between 0.132 and 0.002 eV/atom, see Table 1. Most stable is configuration B, followed by configurations C and D. Least stable is configuration A. Here, the continuation of the In(111) planes across the interface and the variation from Ga to Al cation layers does not allow for an as favorable reduction of local strain as in case of the other interfaces, which even give rise to negative binding energies. The larger structural reconstructions at interfaces B to D compared with A can also be seen in the slightly stronger variation of the respective average lattice constants perpendicular to the interface, $\overline{a}_\perp$ in Table 1. To obtain an estimate of the influence of the lateral strain on the interface energies, we performed calculations for accordingly strained bulk ternary compounds. For the superlattice structures modeled here, we obtain a very moderate contribution of less than 1 meV/atom.

3.4. Interface-dependent Band Alignments

Based on the relaxed interface configurations discussed above, their band alignments are calculated. This is done by referring the valence and conduction band edges to the averaged electrostatic potential $V$ in the respective GaInP and AlInP bulk regions, see, e.g., refs. [36,37]. The valence band offset is given as

$$\Delta E_{\text{VBO}} = \Delta E_{\text{VBM,V}}^\text{GaInP} - \Delta E_{\text{VBM,V}}^\text{AlInP} + \Delta V.$$  

(2)

Here, $\Delta E_{\text{VBM,V}}$ is the difference between $V$ and the valence band edge calculated for bulk GaInP or AlInP within hybrid DFT and $\Delta V$ is the variation of $V$ across the interface, see Figure 3. It is associated with the dipole that is set up across the interface and therefore a ground-state property, which is reliably calculated within DFT-GGA.[36] The values for $\Delta V$ and $\Delta E_{\text{VBO}}$ calculated here for the different interface configurations are summarized in Table 1. As can be seen from Figure 3, six layers are indeed sufficient for the planar averaged electrostatic potential to reach an almost constant value in both supercell regions. This indicates that sufficient material is included in the supercell for reliable calculations. The numerical error bars resulting from the averaging procedure are smaller than 20 meV. The differences in the valence band offsets calculated for thin GaInP films on AlInP substrates compared with the reverse situation are at most 10 meV, i.e., below the numerical error bars. This is due to the nearly perfect lattice match of the two ternary

Table 1. Calculated interface binding energy ($E_B$), average vertical lattice constant ($\overline{a}_\perp$), variation of the electrostatic potential ($\Delta V$) and valence band offset ($\Delta E_{\text{VBO}}$) for the interface configurations shown in Figure 2. Either AlInP or GaInP is supposed to represent the substrate.

<table>
<thead>
<tr>
<th>Interface</th>
<th>A</th>
<th>B</th>
<th>C</th>
<th>D</th>
</tr>
</thead>
<tbody>
<tr>
<td>Substrate</td>
<td>AlInP</td>
<td>GaInP</td>
<td>AlInP</td>
<td>GaInP</td>
</tr>
<tr>
<td>$E_B$ [eV/atom]</td>
<td>0.002</td>
<td>0.002</td>
<td>−0.132</td>
<td>−0.131</td>
</tr>
<tr>
<td>$\overline{a}_\perp$ [Å]</td>
<td>5.71</td>
<td>5.70</td>
<td>5.69</td>
<td>5.68</td>
</tr>
<tr>
<td>$\Delta V$ [eV]</td>
<td>0.74</td>
<td>0.74</td>
<td>0.75</td>
<td>0.76</td>
</tr>
<tr>
<td>$\Delta E_{\text{VBO}}$ [eV]</td>
<td>0.03</td>
<td>0.03</td>
<td>0.04</td>
<td>0.05</td>
</tr>
</tbody>
</table>
compounds. Also the spread of the valence band offsets calculated for the different microscopic interface realizations A to D is very small, only 30 meV. This indicates that the microscopic modeling of interface bonding, strain and dipoles is of minor importance for the band alignment at GaInP/AlInP interfaces. In fact, the microscopic modeling leads to a valence band offset that is at most 110 meV smaller than the value estimated from the branch-point method for ideally CuPt-type ordered crystals. Combining the calculated valence band offsets with the fundamental bandgaps calculated within hybrid DFT for AlInP and GaInP, 2.06 and 1.44 eV, respectively, provides the conduction band offsets. As summarized in Figure 4a, a type-I alignment is predicted here for the interface between CuPt-type ordered alloys, regardless of the actual interface configuration. Still, the valence band offsets calculated here are very small and have to be considered with some caution. Nevertheless, the present calculations agree with an earlier study\cite{7} predicting a type-I alignment, albeit with a slightly larger valence band offset, between randomly ordered alloys.

3.5. Localized States

The type-I band alignment at the interface is also reflected in the spatial localization of the wave functions that form the valence band maximum and conduction band minimum of the superlattice structure used here for interface modeling. As shown in Figure 4b, both are localized in the GaInP region. As expected from the larger energy offset, the confinement of the conduction state is more pronounced than that of the valence state. Interestingly, bound interface states do not occur in the band gap region. However, at the (0.5, 0.5, 0) point of the interface Brillouin zone, around 0.1–0.2 eV below the valence band maximum, bound interface-localized states exist. They correspond to phosphorous states with $p$ character, as exemplarily shown in Figure 5 for the interface B. Specifically, the projection on atomic orbitals shows a contribution of $p_y$ and $p_z$ orbitals that amounts to more than 86%.

4. Conclusion

In conclusion, (hybrid) DFT was used to characterize atomically smooth Ga$_{0.5}$In$_{0.5}$P/Al$_{0.5}$In$_{0.5}$P interfaces between CuPt-type ordered alloys. The interface, where the Ga(111) and In(111) planes of ordered GaInP alternate with In(111) and Al(111) planes of AlInP is most favorable. However, further interface structures occur within an energy range of less than 0.1 eV per interface atom and will therefore form as well. Irrespective of the ordering of the alloys and irrespective of the precise interface configuration, a type-I alignment of the band edges is found. The CuPt-type ordering of the alloys leads to a reduction in the valence band offset and an increase in the conduction band offset by 0.04 and 0.05 eV, respectively, compared with random alloy interfaces. For the interface between perfectly CuPt-ordered alloys, depending on strain and interface configuration, a valence band offset of 0.03–0.06 eV is predicted. There exist no interface states within the energy range of the fundamental gap. However,
slightly below the valence band maximum interface-anion localized $p$ states are detected. The microscopic interface calculations presented here suggest that predictions of the band alignment based on the branchpoint method are reliable within an error bar of 0.1 eV.

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**Conflict of Interest**

The authors declare no conflict of interest.

**Data Availability Statement**

The data that support the findings of this study are available from the corresponding author upon reasonable request.

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AlnP, computational physics, density functional theory, GaInP, heterostructures, interfaces

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